

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
	: Examiner: H. K. Song
Keiko CHIBA et al.)
	: Group Art Unit: 2882
Application No.: 10/736,693)
	: Confirmation No.: 5811
Filed: December 17, 2003)
	: Allowed: November 19, 2004
For: REFLECTION TYPE MASK)
(As Amended)	: February 18, 2005

Mail Stop RCE

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Transmitted herewith is a Preliminary Amendment in the above-identified application.

X No additional claim fee is required.

The fee has been calculated as shown below:

CLAIMS AS AMENDED						
	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST NO. PREVIOUSLY PAID FOR	PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL CLAIMS	9	MINUS	20	= 0	x \$25 \$50	\$0.00
INDEP. CLAIMS	2	MINUS	3	= 0	x \$100 \$200	\$ 0.00
Fee for Multiple Dependent claims \$180/\$360 —						
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT					\$0.00	

	°Verified Statement claiming small entity status is enclosed, if not filed previously.
X	A check in the amount of \$790.00 is enclosed including the Request for Continued Examination (RCE) fee.
	Charge \$ to Deposit Account No. 06-1205. A duplicate of this sheet is enclosed.
X	Any prior general authorization to charge an issue fee under 37 CFR 1.18 to Deposit Account No. 06-1205 is hereby revoked. The Commissioner is hereby authorized to charge any additional fees under 37 CFR 1.16 and 1.17 which may be required during the entire pendency of this application or to credit any overpayment, to Deposit Account No. 06-1205. A duplicate of this paper is enclosed.
	A check in the amount of \$ to cover the fee for a month extension is enclosed.
	A check in the amount of \$ to cover the Information Disclosure Statement fee is enclosed.
X	Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should be directed to our address given below.
	Respectfully submitted,
	Attorney for Applicants Steven E. Warner Registration No. 33,326

FITZPATRICK, CELLA, HARPER & SCINTO 30 Rockefeller Plaza
New York, New York 10112-3801
Facsimile: (212) 218-2200

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PATENT APPLICATION

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PRELIMINARY AMENDMENT

Sir:

Prior to further examination on the merits, please amend the above-identified application as follows: